

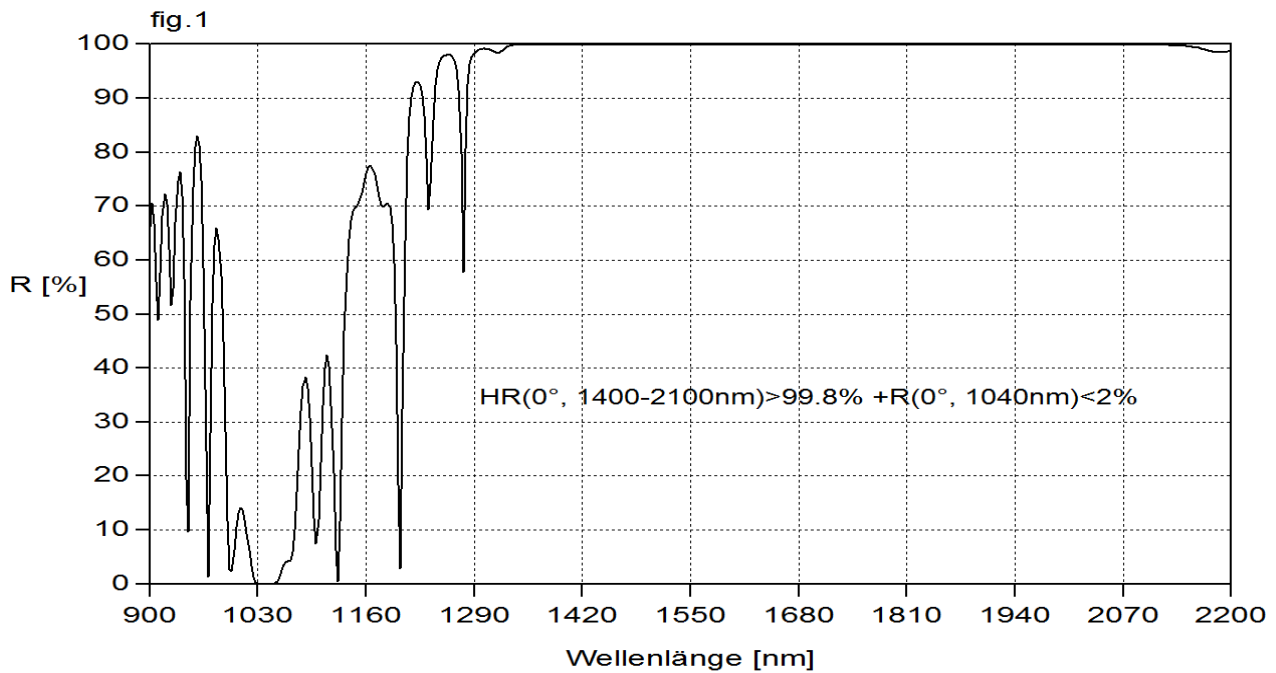
Coating 126761



Magnetron sputtered system

HR(0°, 1400-2100nm)>99.8% +R(0°, 1040nm)<2%
GDD(1400-2100nm) optimized

calculated reflection, 0°



GDD optimized, 0°

